## INFORMATION DISCLOSURE STATEMENT BY APPLICANT

Application No. 10/678,766

Filing Date October 2, 2003

First Named Inventor Tois et al.

Art Unit 1792

Examiner Matthew J. Song

Attorney Docket No. SEPP21.001C1

(Multiple sheets used when necessary)
SHEET 1 OF 2

			U.S. PATENT	DOCUMENTS	
Examiner Initials	Cite No.	Document Number Number - Kind Code (if known) Example: 1,234,567 B1	Publication Date MM-DD-YYYY	Name of Patentee or Applicant	Pages, Columns, Lines Where Relevant Passages or Relevant Figures Appear
	1	5,187,241	02-16-1993	Buchwalter et al.	
	2	5,496,597	03-05-1996	Soininen et al.	
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Examiner Initials	Cite No.	Foreign Patent Document Country Code-Number-Kind Code Example: JP 1234567 A1	Publication Date MM-DD-YYYY	Name of Patentee or Applicant	Pages, Columns, Lines Where Relevant Passages or Relevant Figures Appear	T <sup>1</sup>
	15	JP 03082769 A	04-1991	Tanaka, Naoto		Abstract
	16	JP 06080413 A	03-1994	Maruyama, Toshiro		Abstract
	17	JP 53148282 A	12-1978	Usuki et al.		

		NON PATENT LITERATURE DOCUMENTS	
Examiner Initials	Cite No.	Include name of the author (in CAPITAL LETTERS), title of the article (when appropriate), title of the item (book, magazine, journal, serial, symposium, catalog, etc.), date, page(s), volume-issue number(s), publisher, city and/or country where published.	T <sup>1</sup>
	18	ESAKI, L.; R. Tsu. "Superlattice and Negative Differential Conductivity in Semiconductors," <i>IMB J.Res. Develop.</i> , January 1970.	
	19	GASSER et al., "Quasi-monolayer deposition of silicon dioxide", Thin Solid films, 250 (1994) pg. 213-218.	
	20	LESKELA et al., "ALD precursor chemistry: Evolution and future challenges," <i>J. Phys. IV France</i> 9: 837-847 (1999).	

Ex	aminer Signature	Date Considered

\*Examiner: Initial if reference considered, whether or not citation is in conformance with MPEP 609. Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.

T<sup>1</sup> - Place a check mark in this area when an English language Translation is attached.

PTO/SB/08 Equivalent

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-	21	MORISHITA et al, "New Substances for Atomic-Layer Deposition of Silicon Dioxide," <i>Journal of Non-Chrystalline Solids</i> , 187 (1995) pg 66-69.		

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**Examiner Signature** 

**Date Considered** 

<sup>\*</sup>Examiner: Initial if reference considered, whether or not citation is in conformance with MPEP 609. Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.